

## INFORMATION DISCLOSURE STATEMENT

Applicant : Ando et al.  
App. No : 10/572,709  
Filed : March 17, 2006  
For : POSITIVE RESIST COMPOSITION  
AND RESIST LAMINATE FOR LOW-  
ACCELERATION ELECTRON BEAM  
AND METHOD OF PATTERN  
FORMATION  
Examiner : Richard L. Schilling  
Art Unit : 1795

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I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

April 23, 2008

(Date)

Neil S. Bartfield, Ph.D., Reg. No. 39,901

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 5 (five) references to be considered by the Examiner. Also enclosed are 2 (two) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required. If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON &amp; BEAR, LLP

Dated: 4/23/08

By: 

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